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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/842,802	04/27/2001	Takao Noguchi	206645US0	2819
22850	7590	04/01/2004	EXAMINER	
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C. 1940 DUKE STREET ALEXANDRIA, VA 22314			SONG, MATTHEW J	
			ART UNIT	PAPER NUMBER
			1765	
DATE MAILED: 04/01/2004				

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary

Application No.

09/842,802

Applicant(s)

NOGUCHI ET AL.

Examiner

Matthew J Song

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 23 December 2003.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1,2 and 4-9 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1,2 and 4-9 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
 2. ☐ Certified copies of the priority documents have been received in Application No. _____.
 3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- 1) ☒ Notice of References Cited (PTO-892)
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
- 3) ☐ Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date _____
- 4) ☐ Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____
- 5) ☐ Notice of Informal Patent Application (PTO-152)
- 6) ☐ Other: _____

DETAILED ACTION

Claim Rejections - 35 USC § 112

1. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

2. Claim 1 is rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter, which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. Claim 1 recites, “ a ferroelectric thin film, which is not the second perovskite oxide thin film, that is epitaxially grown on said second perovskite oxide thin film” in last two lines. Any negative limitation or exclusionary proviso must have basis in the original disclosure and the mere absence of a positive recitation is not basis for an exclusion (MPEP 2173.05 (i)). The instant specification does not provide support for the negative limitation. The instant specification does teach specific example, where the ferroelectric film is composed of a different material from the second perovskite oxide film. However, the specification broadly teaches the second perovskite oxide film is PbTiO_3 and the ferroelectric film is a Pb-based perovskite compound, which would encompass the PbTiO_3 used as the second perovskite oxide film. Therefore, there is no specific teaching that the ferroelectric film is not the second perovskite.

Claim Rejections - 35 USC § 103

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3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

4. Claims 1, 2 and 4-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yano et al (US 5,801,105) in view of Summerfelt (US 5,393,352) or Tarui et al (US 5,674,563).

Yano et al discloses a multilayer thin film of BaTiO₃ (001)/Pt (001)/BaTiO₃ (001)/ ZrO₂ (001)/Si (100), note column 28, lines 54-67. The ZrO₂ (001) layer reads on applicant's buffer layer of an oxide thin film of zirconium or of a rare earth element. Yano et al also discloses tungsten bronze type compounds and the perovskite compounds used are BaTiO₃, SrTiO₃, PLZT, PZT, CaTiO₃ and PbTiO₃ (col 12, ln 15-55). Yano et al also discloses the substrate can be gallium arsenide and Si (100) (col 12, ln 55-65). Yano et al also discloses a perovskite/film composed of zirconium oxide stabilized with rare earth metal element/silicon structure is

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effective for improving the crystallinity of an oriented film to formed thereon, for example, films of ferroelectric materials and electrode films of Pt (col 14, ln 20-35).

Yano et al does not teach the ferroelectric film is not the second perovskite oxide thin film, that is grown on the second perovskite oxide thin film.

In a method of using a perovskite buffer, note entire reference, Summerfelt teaches a SrTiO_3 (ST) or BaTiO_3 (BT) can be used as a buffer layer between Pt and PZT. ST and BT are inherently perovskites. Summerfelt also teaches the ST or BT buffer improves the properties by acting as a diffusion barrier and ST will act as a nucleation layer for the perovskite structure of PZT (col 4, ln 35-68), where the buffer layer reads on applicants' second perovskite and PZT reads on applicants ferroelectric. It would have been obvious to a person of ordinary skill in the art at the time of the invention to modify Yano et al by using a buffer layer of SrTiO_3 or BaTiO_3 between a layer of Platinum and PZT to improve the properties of the ferroelectric PZT layer, as taught by Summerfelt.

In a method of forming a ferroelectric thin film, note entire reference, Tarui et al teaches forming PZT on a Pt substrate using a PbTiO_3 buffer layer to improve the flatness of the PZT ferroelectric thin film (col 17, ln 1-25 and col 5, ln 35-67). It would have been obvious to a person of ordinary skill in the art at the time of the invention to modify Yano et al by using a PbTiO_3 buffer between Pt and PZT to improve the flatness of a PZT layer, as taught by Tarui et al.

Referring to claim 2, the combination of Yano et al and Summerfelt or the combination of Yano et al and Tarui et al is silent to the perovskite has insulating properties, however this is inherent to the combination of Yano et al and Summerfelt or the combination of Yano et al and

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Tarui et al because the combination of Yano et al and Summerfelt or the combination of Yano et al and Tarui et al teaches a similar material as applicant, therefore a similar material will inherently have similar properties.

Referring to claim 4-5, combination of Yano et al and Summerfelt or the combination of Yano et al and Tarui et al teaches tungsten bronze type compounds and the perovskite compounds used are BaTiO₃, SrTiO₃, PLZT, PZT, CaTiO₃ and PbTiO₃ (col 12, ln 15-55).

Referring to claim 6, the combination of Yano et al and Summerfelt or the combination of Yano et al and Tarui et al teaches fabricating electronic devices, such as volatile memories, infrared sensors, optical modulators and superconducting sensors (Yano col 29, ln 25-50).

5. Claims 1, 2 and 4-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yano et al (JP 10-017394), an English computer translation (CT) and an English Abstract have been provided, in view of Summerfelt (US 5,393,352) or Tarui et al (US 5,674,563).

Yano et al teaches a single crystal silicon substrate, a ZrO₂ thin film (intermediate thin film), a BaTiO₃ film (insulative ground thin film), a Pt film (conductive ground thin film) and a ferroelectric thin film were formed in this order (CT pg 20 [0151])). The ZrO₂ thin film reads on applicants buffer layer, the BaTiO₃ reads on applicant's Perovskite layer and the Pt layer reads on applicants electrically conductive layer. Yano et al also discloses the insulative subbing layer has perovskite crystal structure of ABO₃, where A is Pb and B is Ti; this reads on applicant's PbTiO₃. Yano et al also discloses the insulative subbing thin film has a (001) or (100) unidirectional orientation (CT pg 7 [0036]-[0038]). Yano et al also discloses the zirconium oxide thin film is composed mainly of zirconium oxide or zirconium oxide stabilized with a rare earth

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metal (CT pg 8 [0045]). Yano et al also discloses a silicon substrate with a (100) orientation (CT [0030]). Yano et al also structure of this invention can form electronic devices (CT pg 12 [0074]). Yano et al also discloses in the ferroelectric thin film of PbTiO_3 , where part of Ti may be replaced by at least Zr (CT pg 7 [0033] and pg 6 [0025]-[0029]), this reads on applicant's PZT.

Yano et al does not teach the ferroelectric film is not the second perovskite oxide thin film, that is grown on the second perovskite oxide thin film.

In a method of using a perovskite buffer, note entire reference, Summerfelt teaches a SrTiO_3 (ST) or BaTiO_3 (BT) can be used as a buffer layer between Pt and PZT. ST and BT are inherently perovskites. Summerfelt also teaches the ST or BT buffer improves the properties by acting as a diffusion barrier and ST will act as a nucleation layer for the perovskite structure of PZT (col 4, ln 35-68), where the buffer layer reads on applicants' second perovskite and PZT reads on applicants ferroelectric. It would have been obvious to a person of ordinary skill in the art at the time of the invention to modify Yano et al by using a buffer layer of SrTiO_3 or BaTiO_3 between a layer of Platinum and PZT to improve the properties of the ferroelectric PZT layer, as taught by Summerfelt.

In a method of forming a ferroelectric thin film, note entire reference, Tarui et al teaches forming PZT on a Pt substrate using a PbTiO_3 buffer layer to improve the flatness of the PZT ferroelectric thin film (col 17, ln 1-25 and col 5, ln 35-67). It would have been obvious to a person of ordinary skill in the art at the time of the invention to modify Yano et al by using a PbTiO_3 buffer between Pt and PZT to improve the flatness of a PZT layer, as taught by Tarui et al.

6. Claims 1, 2 and 4-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yano et al (JP 10-017394), where US 6,121,647 is used as an accurate translation of JP 10-017394, in view of Summerfelt (US 5,393,352) or Tarui et al (US 5,674,563).

Yano et al teaches a single crystal silicon substrate, a ZrO_2 thin film (intermediate thin film), a $BaTiO_3$ film (insulative subbing thin film), a Pt film and a ferroelectric thin film were formed in the described order ('647 col 26, ln 40-60). The ZrO_2 thin film reads on applicants buffer layer, the $BaTiO_3$ reads on applicant's Perovskite layer and the Pt layer reads on applicants electrically conductive layer. Yano et al also discloses the insulative subbing layer has perovskite crystal structure of ABO_3 , where A is Pb and B is Ti; this reads on applicant's $PbTiO_3$. Yano et al also discloses the insulative subbing thin film has a (001) or (100) unidirectional orientation ('647 col 10, ln 15-55. Yano et al also discloses the zirconium oxide thin film is composed mainly of zirconium oxide or zirconium oxide stabilized with a rare earth metal ('647 col 45-67). Yano et al also discloses a silicon substrate with a (100) orientation ('647 col 9, ln 60 to col 10, ln 15). Yano et al also discloses the film structure can form electronic devices ('647 col 16, ln 5-20). Yano et al also discloses in the ferroelectric thin film of $PbTiO_3$, where part of Ti may be replaced by at least Zr ('647 col 9, ln 55-65 and col 8, ln 10-67), this reads on applicant's PZT.

Yano et al does not teach the ferroelectric film is not the second perovskite oxide thin film, that is grown on the second perovskite oxide thin film.

In a method of using a perovskite buffer, note entire reference, Summerfelt teaches a $SrTiO_3$ (ST) or $BaTiO_3$ (BT) can be used as a buffer layer between Pt and PZT. ST and BT are

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inherently perovskites. Summerfelt also teaches the ST or BT buffer improves the properties by acting as a diffusion barrier and ST will act as a nucleation layer for the perovskite structure of PZT (col 4, ln 35-68), where the buffer layer reads on applicants' second perovskite and PZT reads on applicants ferroelectric. It would have been obvious to a person of ordinary skill in the art at the time of the invention to modify Yano et al by using a buffer layer of SrTiO_3 or BaTiO_3 between a layer of Platinum and PZT to improve the properties of the ferroelectric PZT layer, as taught by Summerfelt.

In a method of forming a ferroelectric thin film, note entire reference, Tarui et al teaches forming PZT on a Pt substrate using a PbTiO_3 buffer layer to improve the flatness of the PZT ferroelectric thin film (col 17, ln 1-25 and col 5, ln 35-67). It would have been obvious to a person of ordinary skill in the art at the time of the invention to modify Yano et al by using a PbTiO_3 buffer between Pt and PZT to improve the flatness of a PZT layer, as taught by Tarui et al.

7. Claim 9 is rejected under 35 U.S.C. 103(a) as being unpatentable over Yano et al (US 5,801,105) or Yano et al (JP 10-017394), where an English computer translation (CT) and an English Abstract have been provided; or Yano et al (JP 10-017394), where US 6,121,647 is used as an accurate translation of JP 10-017394; in view of Summerfelt (US 5,393,352) or Tarui et al (US 5,674,563), as applied to claims 1,2 and 4-8 above, and further in view of Moon (US 5,744,374) or Nashimoto (US 5,834,803).

The combination of Yano et al ('105) and Summerfelt or the combination of Yano ('105) and Tarui et al or the combination of Yano et al ('394) and Summerfelt or the combination of

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Yano et al ('394) and Tarui et al teaches all of the limitations of claim 9 including a ZrO_2 layer on a silicon substrate, as discussed previously, except the buffer layer comprises Y_2O_3 .

In a method of forming a ferroelectric film, note entire reference, Moon teaches a Silicon substrate and a yttrium oxide (Y_2O_3) film over the substrate and a ferroelectric film formed over the yttrium oxide layer (col 4, ln 40-55). Moon also teaches when a PT ($PbTiO_3$) ferroelectric film is formed on the yttrium oxide film it is possible to form a good quality ferroelectric film can be formed on a silicon semiconductor substrate (col 4, ln 1-15 and col 5, ln 1-5). It would have been obvious to a person of ordinary skill in the art at the time of the invention to modify the combination of Yano et al ('105) and Summerfelt or the combination of Yano ('105) and Tarui et al or the combination of Yano et al ('394) and Summerfelt or the combination of Yano et al ('394) and Tarui et al with Moon's yttrium layer between a silicon substrate and a PT layer to form a good quality film.

In a method of forming a ferroelectric film, note entire reference, Nashimoto teaches a single crystal substrate 1 of silicon (100) (col 3, ln 65 to col 4, ln 5 and col 10, ln 20-35), an epitaxial buffer layer 5 of MgO , ZrO_2 or Y_2O_3 (col 4, ln 10-15), a first ferroelectric thin film layer 2 and a second ferroelectric thin film layer 3, thereon. Nashimoto also teaches the first and second ferroelectric thin films include ABO_3 type ferroelectric substances such as $LiNbO_3$, PZT, $BaTiO_3$ and $PbTiO_3$ (col 4, ln 16-67 and col 10, ln 35-40). Nashimoto also teaches a $PbTiO_3$ (001) film grown on a buffer and the $PbTiO_3$ is a perovskite (col 10, ln 41-67). Nashimoto also teaches the first and second ferroelectric thin films may be formed from different ferroelectric substances (col 4, ln 55-60). It would have been obvious to a person of ordinary skill in the art at the time of the invention to modify the combination of Yano et al ('105) and Summerfelt or the

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combination of Yano ('105) and Tarui et al or the combination of Yano et al ('394) and Summerfelt or the combination of Yano et al ('394) and Tarui et al ZrO₂ layer by substituting Nashimoto's Y₂O₃ layer because substitution of known equivalents for the same purpose is held to be obvious. (MPEP 2144.06).

Response to Arguments

8. Applicant's arguments with respect to claims 1, 2 and 4-9 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

9. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Matthew J Song whose telephone number is 571-272-1468. The examiner can normally be reached on M-F 9:00-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 571-272-1465. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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Matthew J Song
Examiner
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MJS

NADINE G. NORTON
SUPERVISORY PATENT EXAMINER

A handwritten signature in black ink, appearing to read 'Nadine', written over the printed name of the supervisor.